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(12) **United States Design Patent**  
**Park et al.**

(10) **Patent No.:** **US D977,086 S**  
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- (54) **SANITARY MASK**
- (71) Applicant: **R&F Chemical Co., Ltd.**, Hanam-si (KR)
- (72) Inventors: **Dongil Park**, Seoul (KR); **Soojeong Lee**, Seoul (KR); **Nayoung Heo**, Seoul (KR); **Junyeop Shim**, Hanam-si (KR); **Jaehong Lee**, Gwangju-si (KR)
- (73) Assignee: **R&F Chemical Co., Ltd.**, Hanam-si (KR)

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(Continued)

- (\*\*) Term: **15 Years**
- (21) Appl. No.: **29/748,863**
- (22) Filed: **Sep. 1, 2020**

*Primary Examiner* — Richard Kearney  
*Assistant Examiner* — Michael Hoffman  
 (74) *Attorney, Agent, or Firm* — Bridgeway IP Law Group, PLLC; Jihun Kim

(30) **Foreign Application Priority Data**

Jul. 28, 2020 (KR) ..... 30-2020-0034917

(51) **LOC (14) Cl.** ..... **29-02**

(52) **U.S. Cl.**  
USPC ..... **D24/110.1; D29/108**

(58) **Field of Classification Search**  
 USPC ..... D24/110, 110.1–110.6; D29/108  
 CPC . A41D 13/11; A41D 13/1107; A41D 13/1115;  
 A41D 13/1123; A41D 13/113; A41D  
 13/1138; A41D 13/1146; A41D 13/1153;  
 A41D 13/1161; A41D 13/1169; A41D  
 13/1176; A61M 16/06; A62B 18/00;  
 A62B 18/02; A62B 18/025; A62B 23/00  
 See application file for complete search history.

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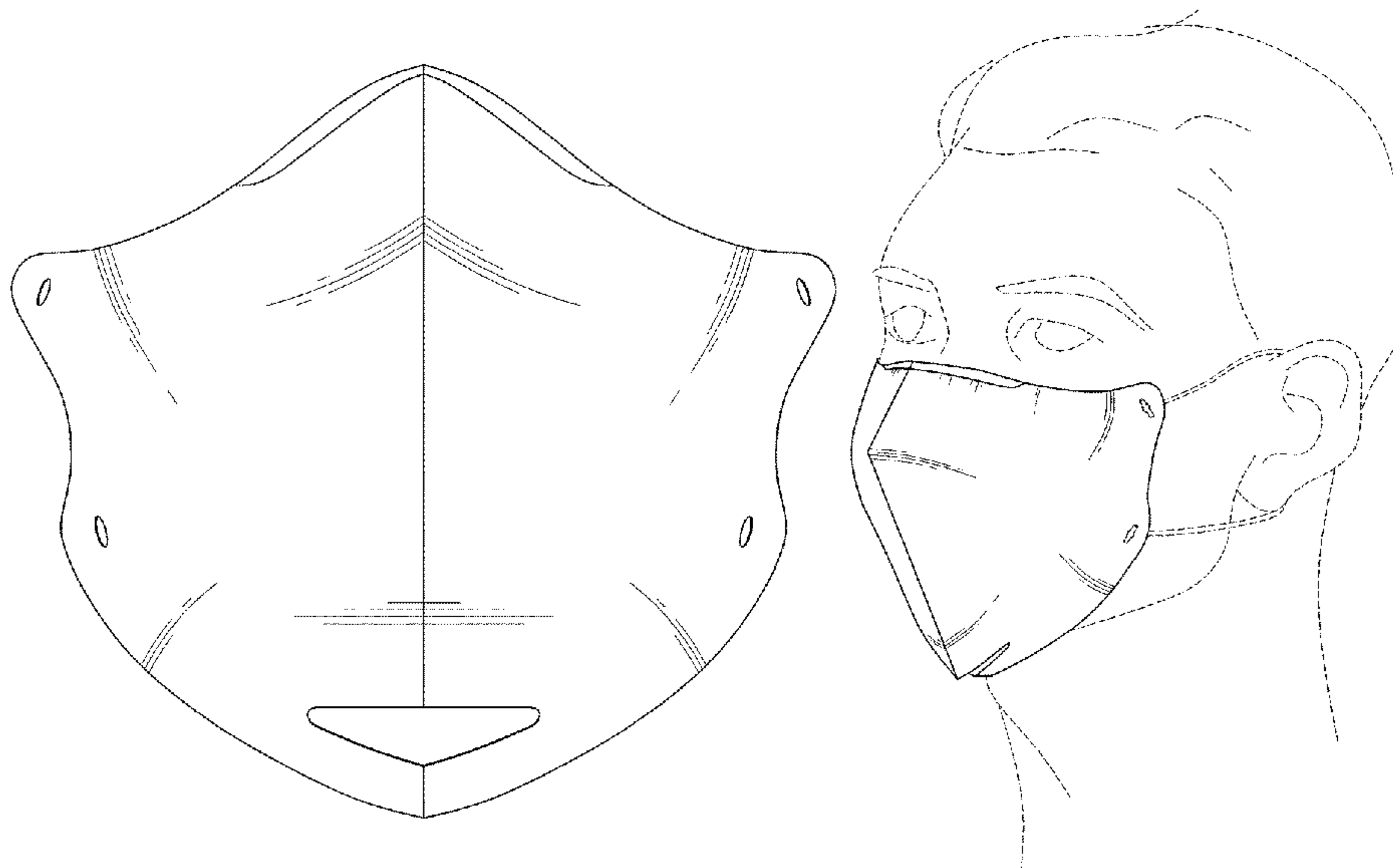
(57) **CLAIM**

We claim the ornamental design for a sanitary mask, as shown and described.

**DESCRIPTION**

FIG. 1 is a bottom perspective view of a sanitary mask, showing our design;  
 FIG. 2 is a front elevational view thereof;  
 FIG. 3 is a rear elevational view thereof;  
 FIG. 4 is a left side elevational view thereof;  
 FIG. 5 is a right side elevational view thereof;  
 FIG. 6 is a top plan view thereof;  
 FIG. 7 is a bottom plan view thereof;  
 FIG. 8 is a top perspective view thereof;  
 FIG. 9 is a rear perspective view thereof;  
 FIG. 10 is an exploded view thereof; and,  
 FIG. 11 is a reference view thereof showing the sanitary mask in use.  
 The broken lines in the drawings show portions of the sanitary mask or environment which form no part of the claimed design.

**1 Claim, 11 Drawing Sheets**



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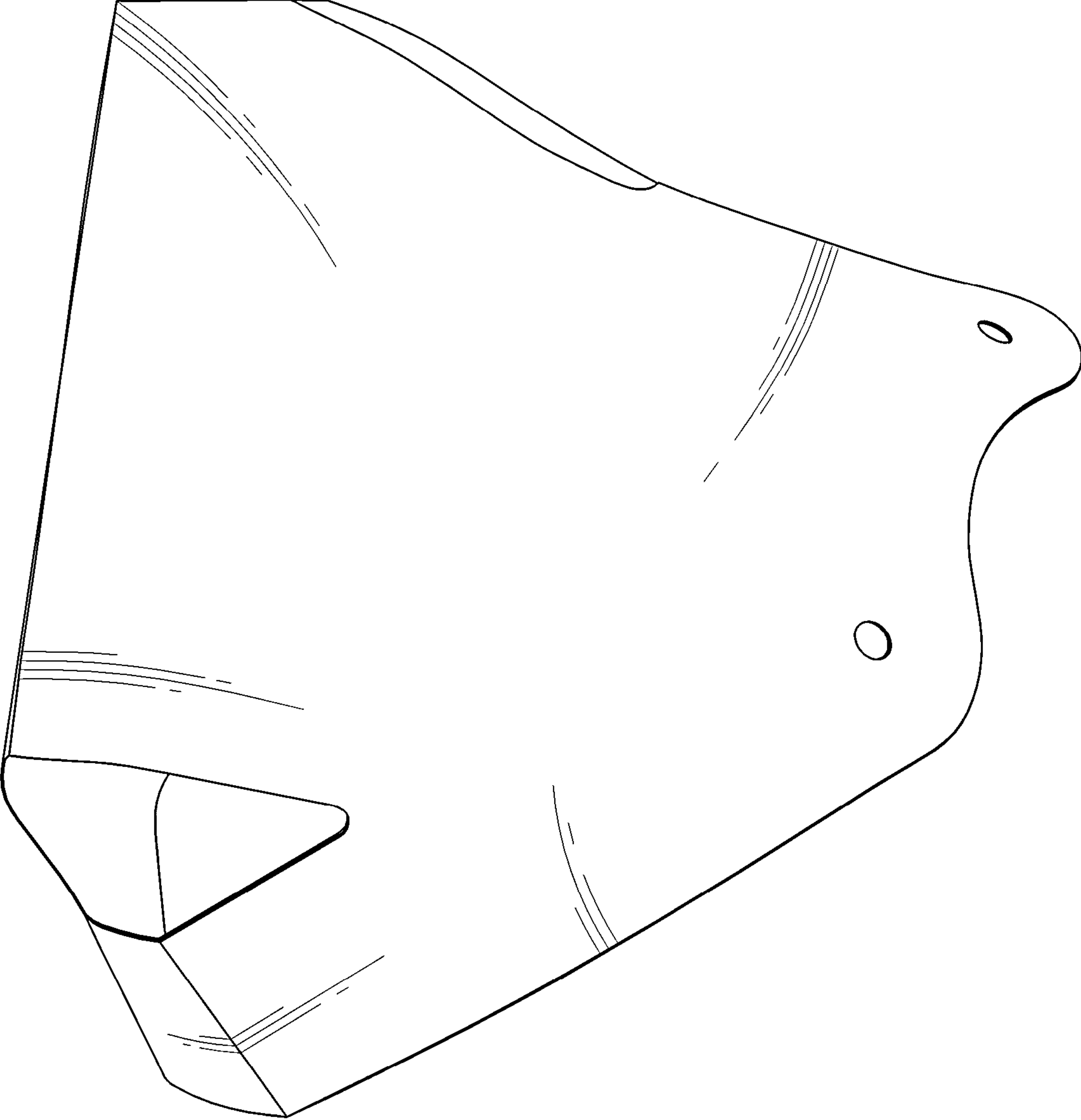


FIG. 1

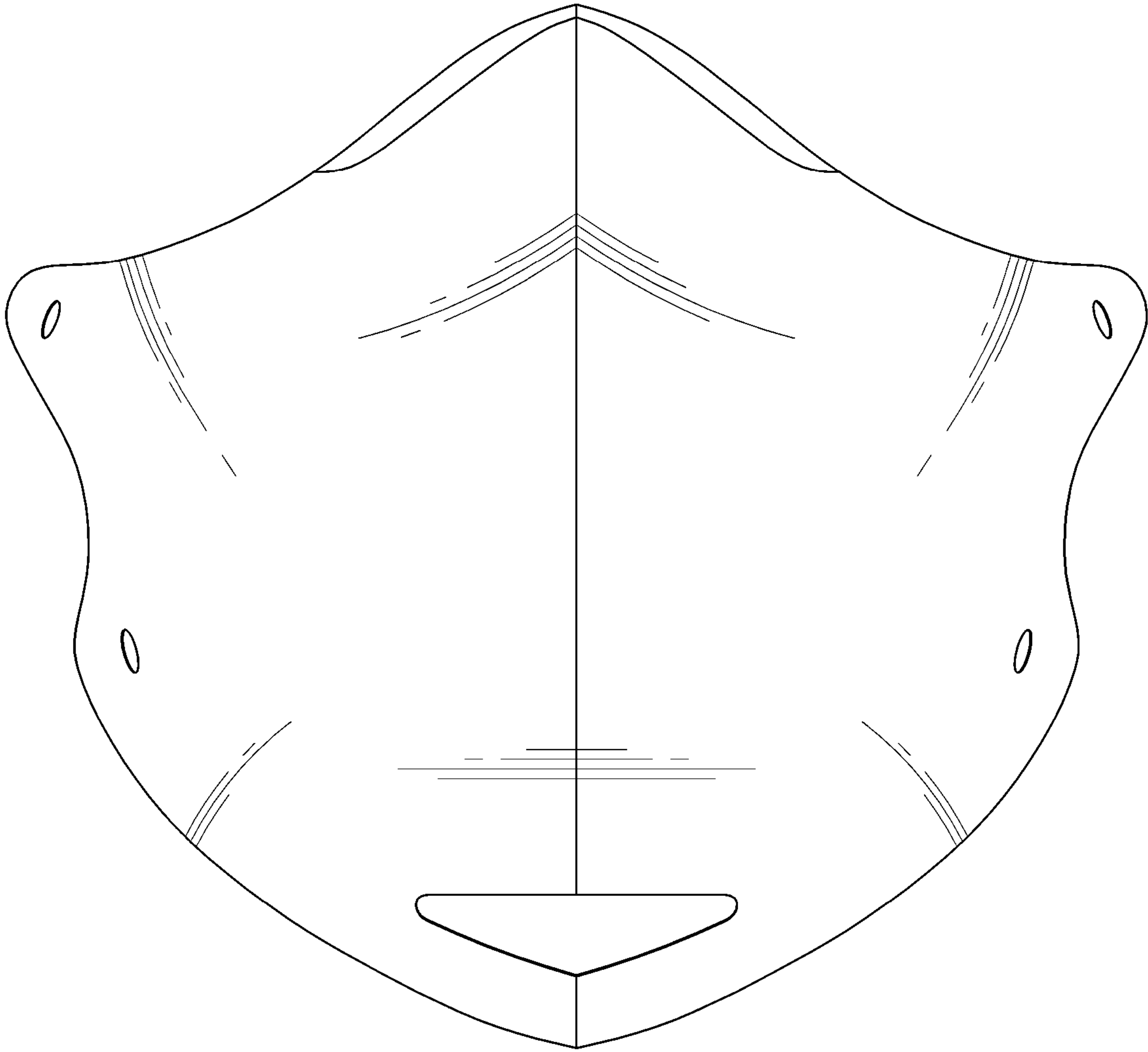


FIG. 2

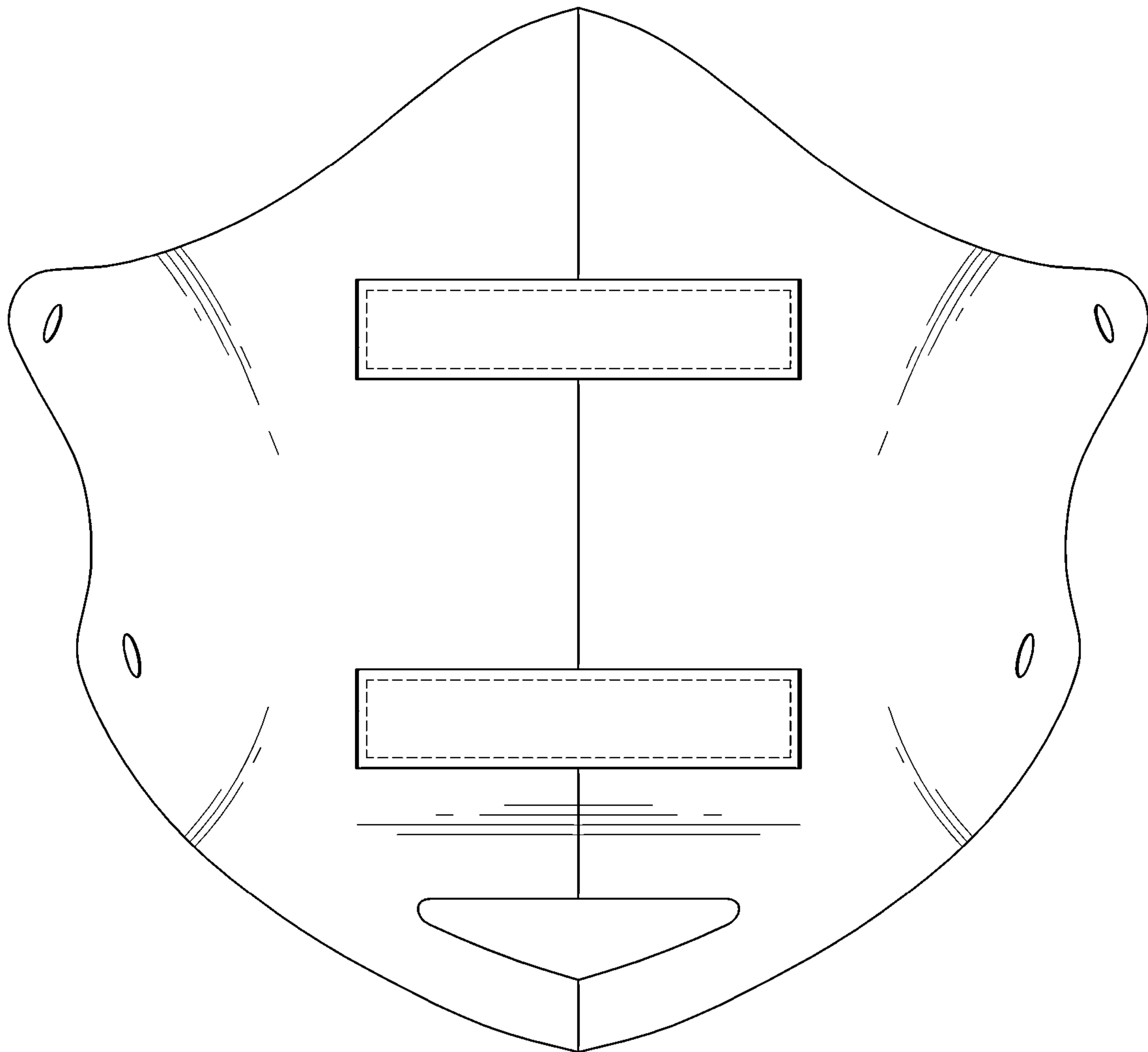


FIG. 3

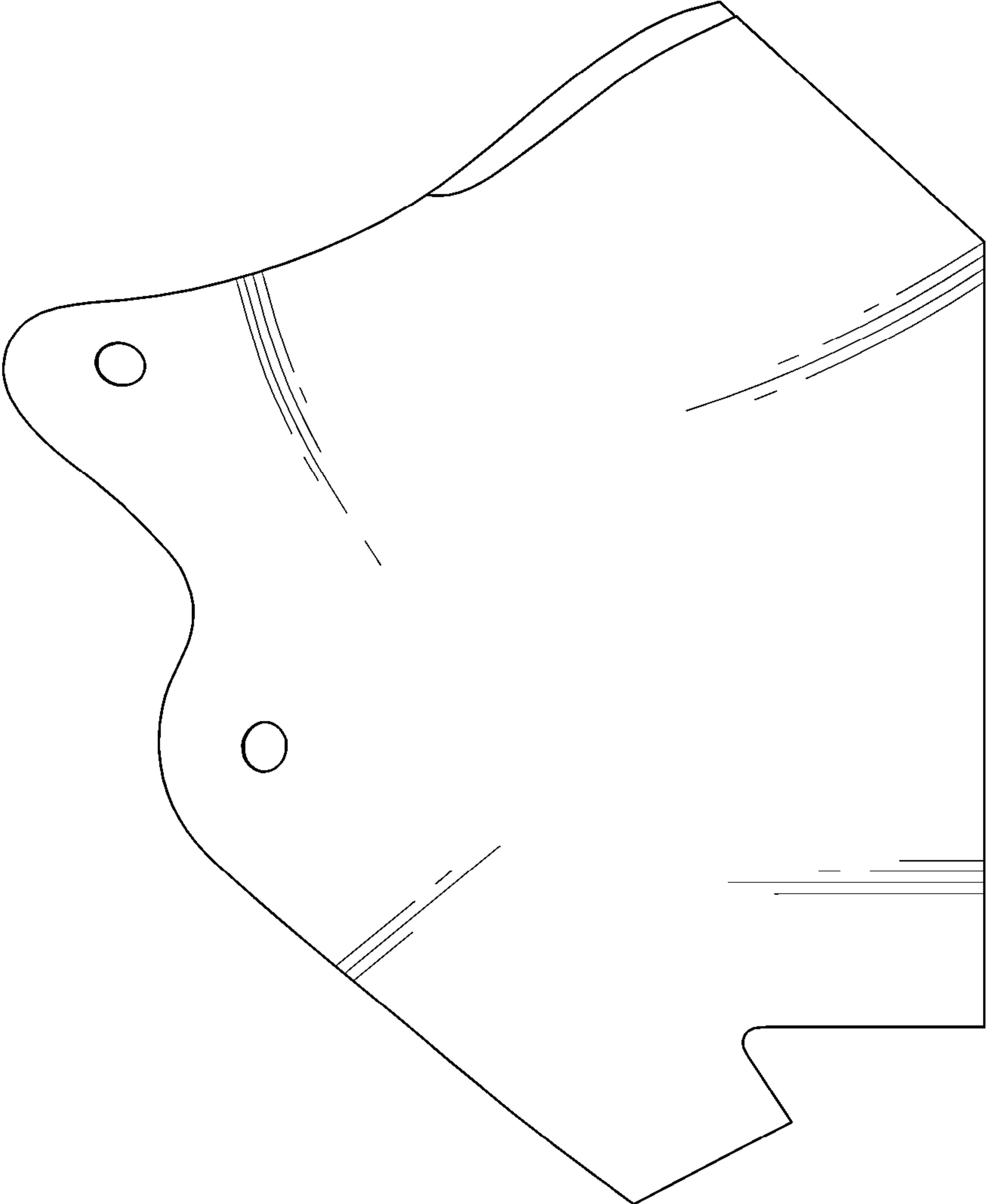


FIG. 4

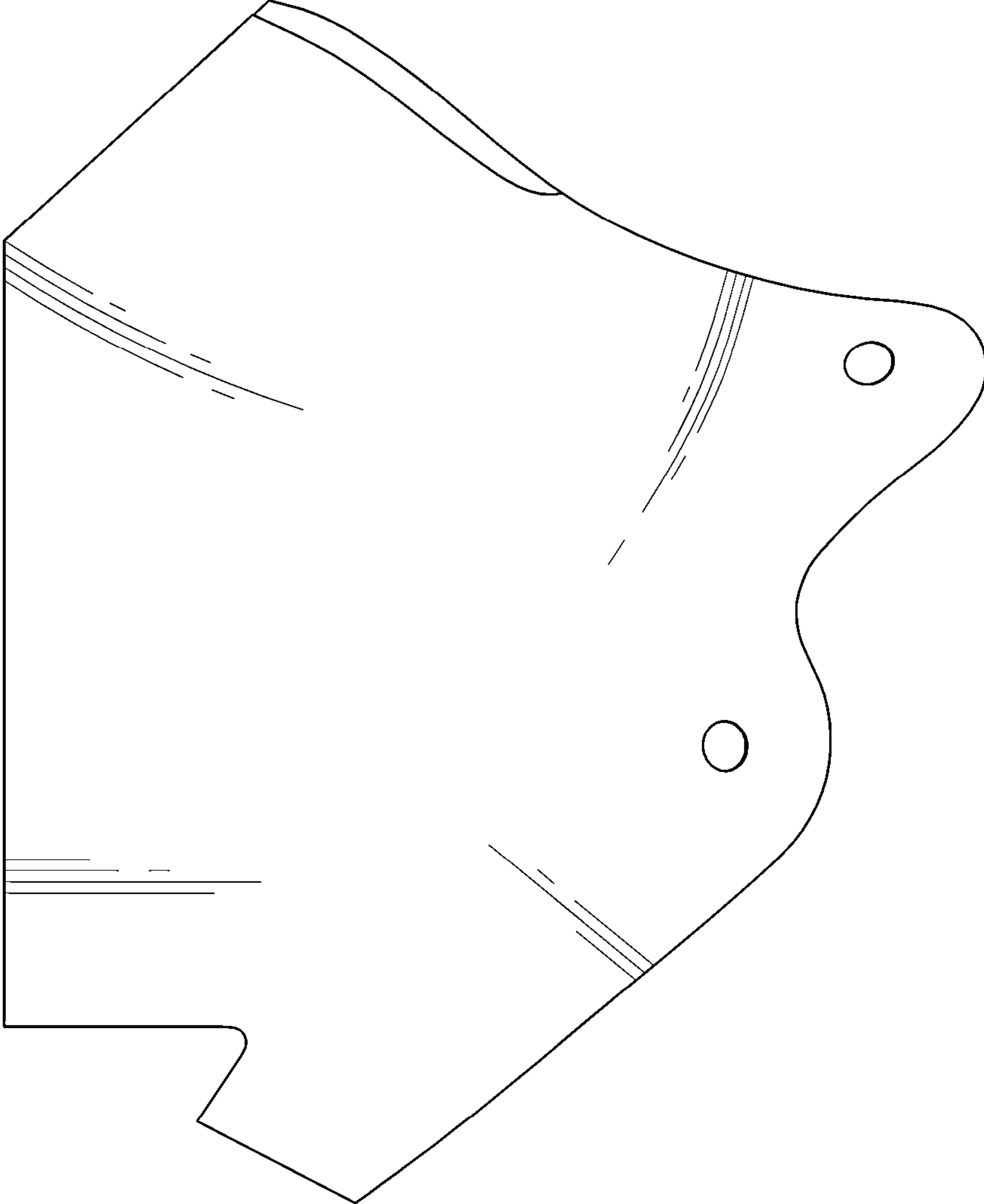
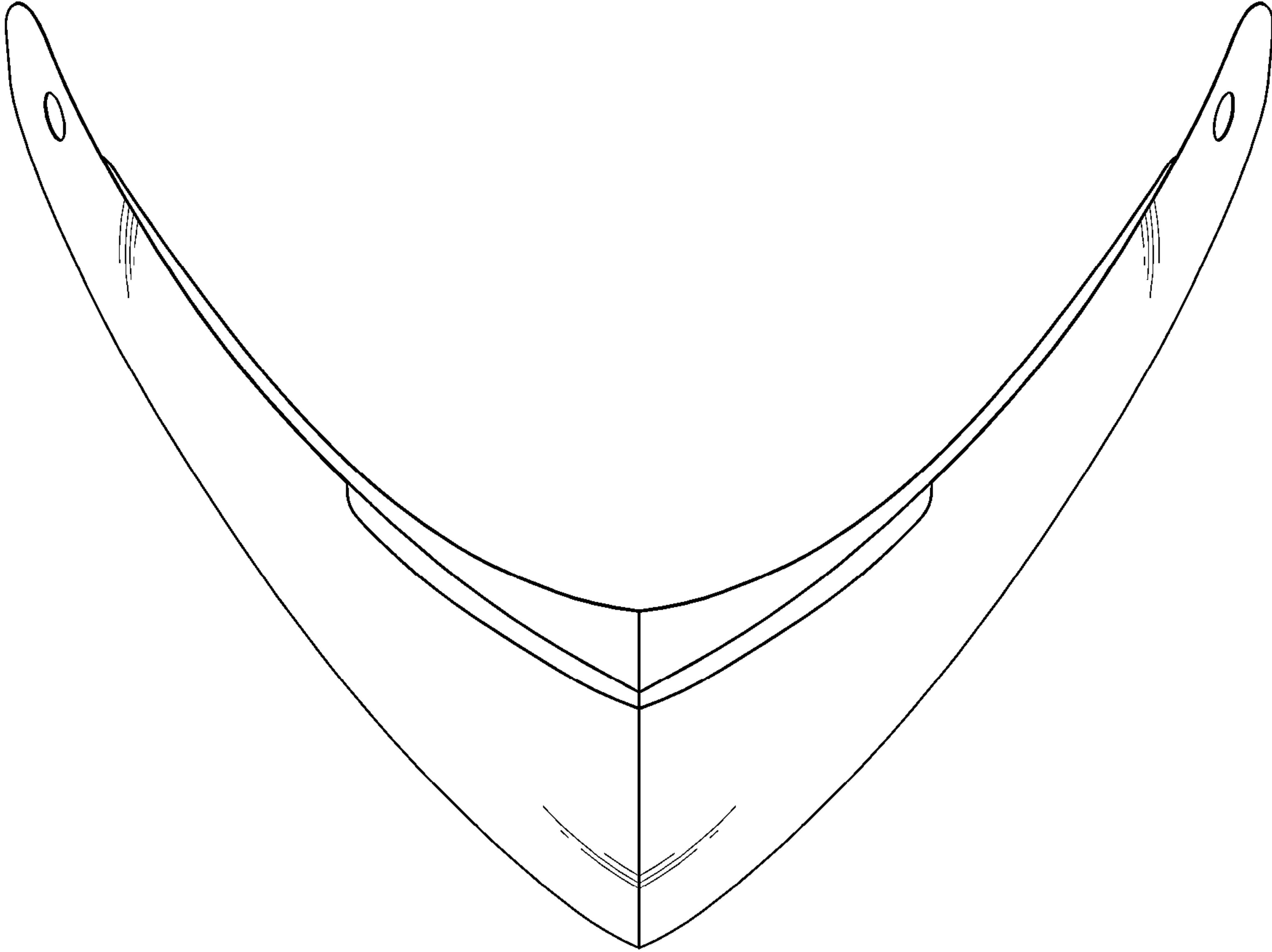


FIG. 5



**FIG. 6**



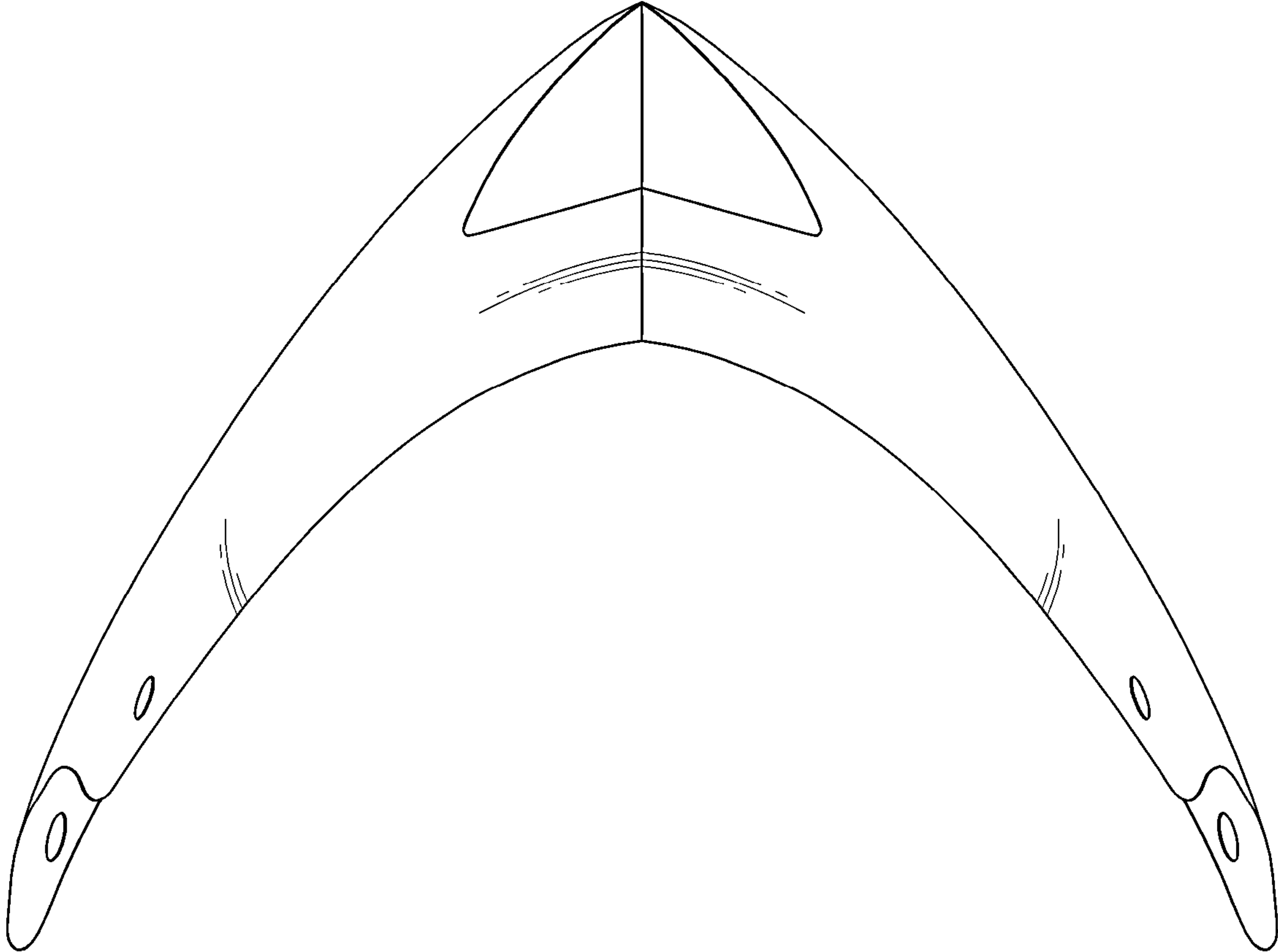


FIG. 7

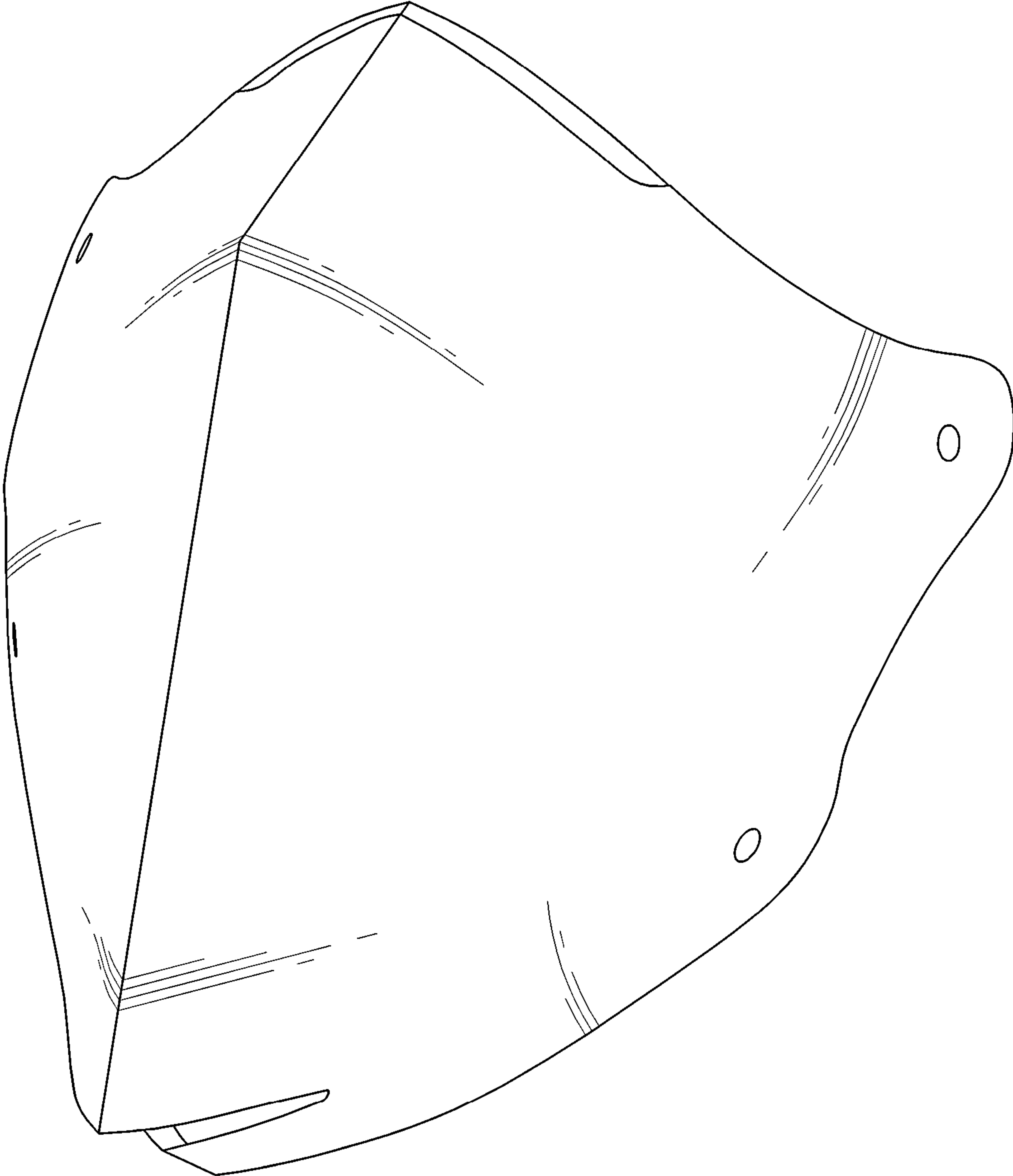


FIG. 8

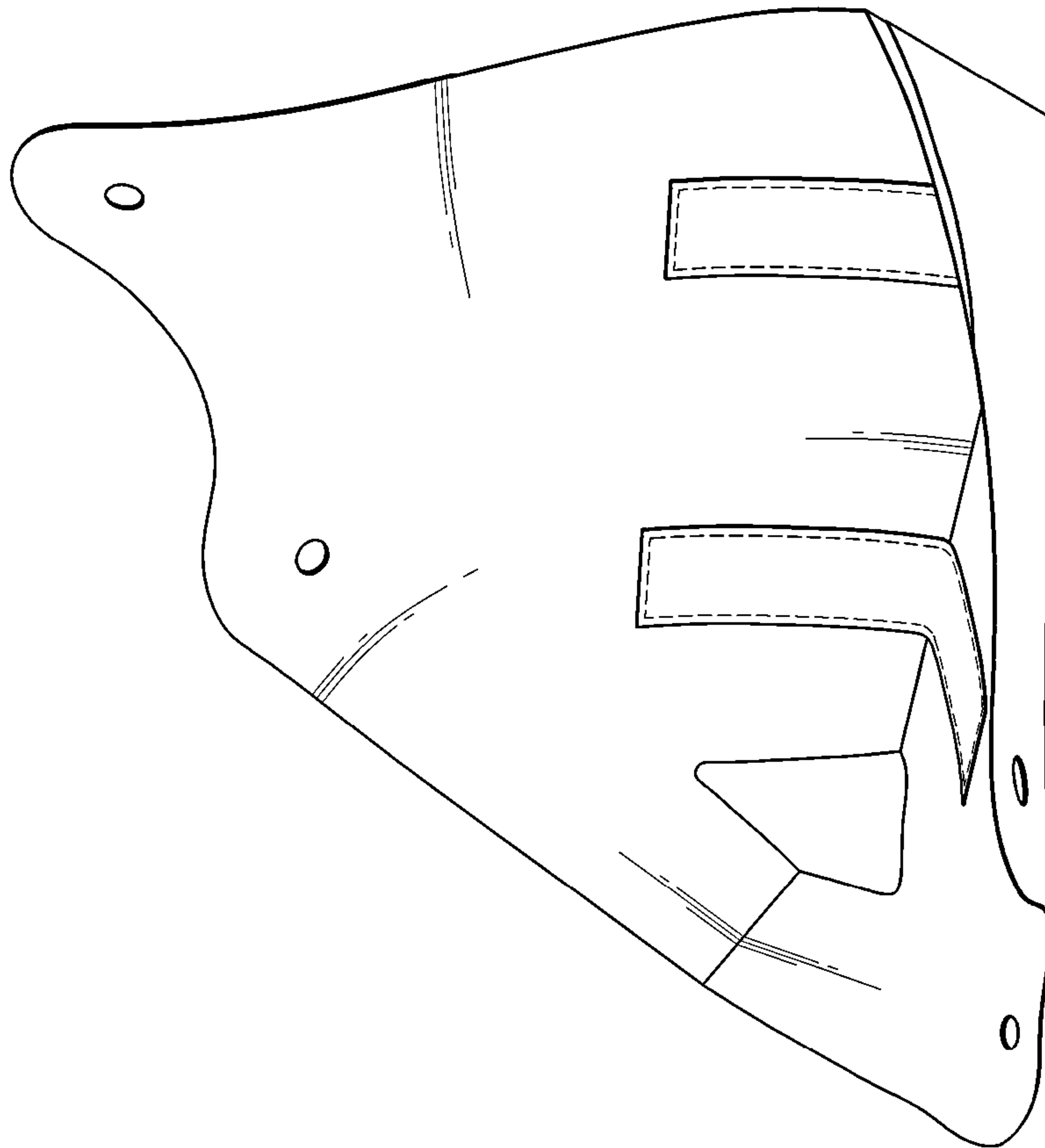


FIG. 9

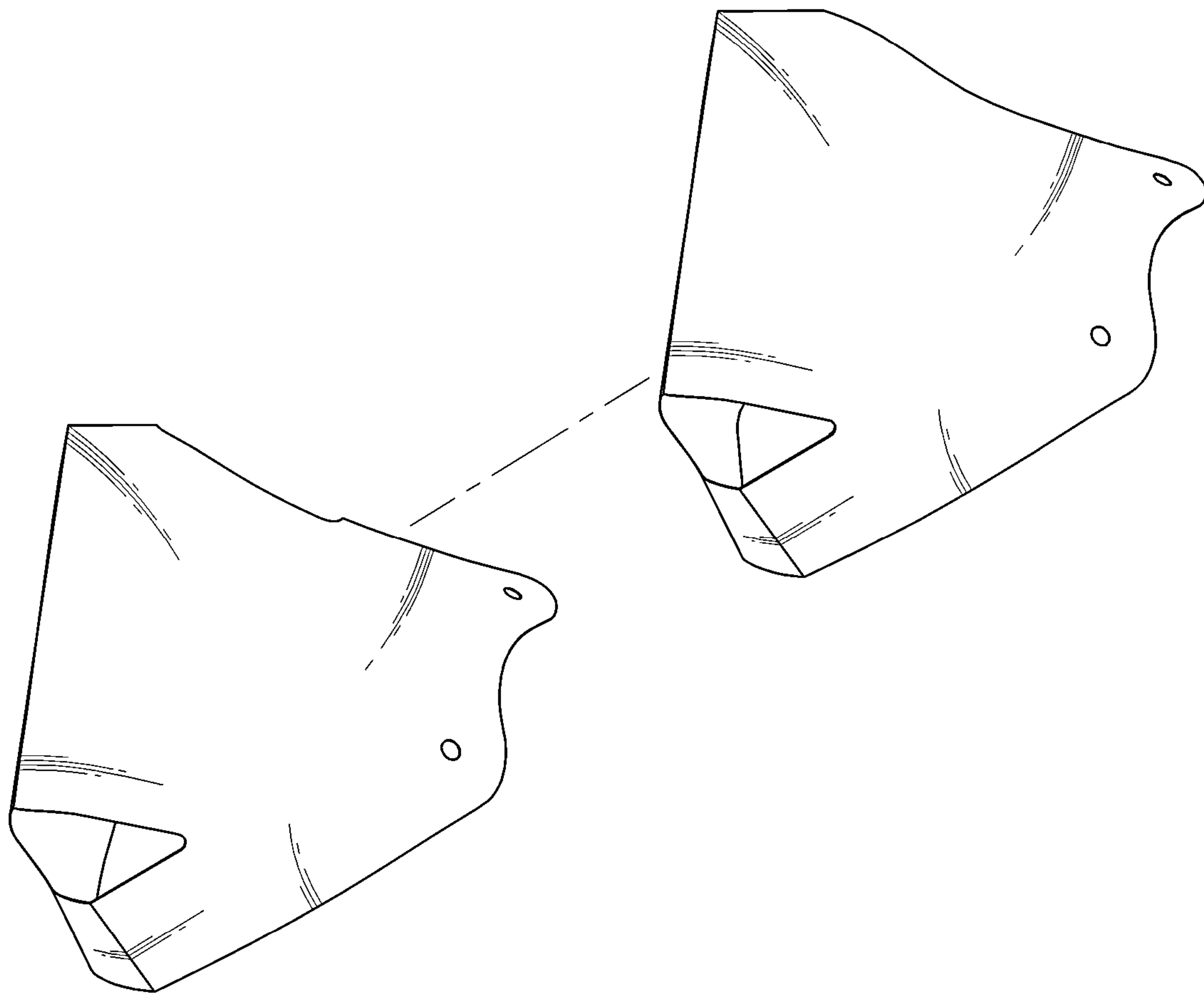
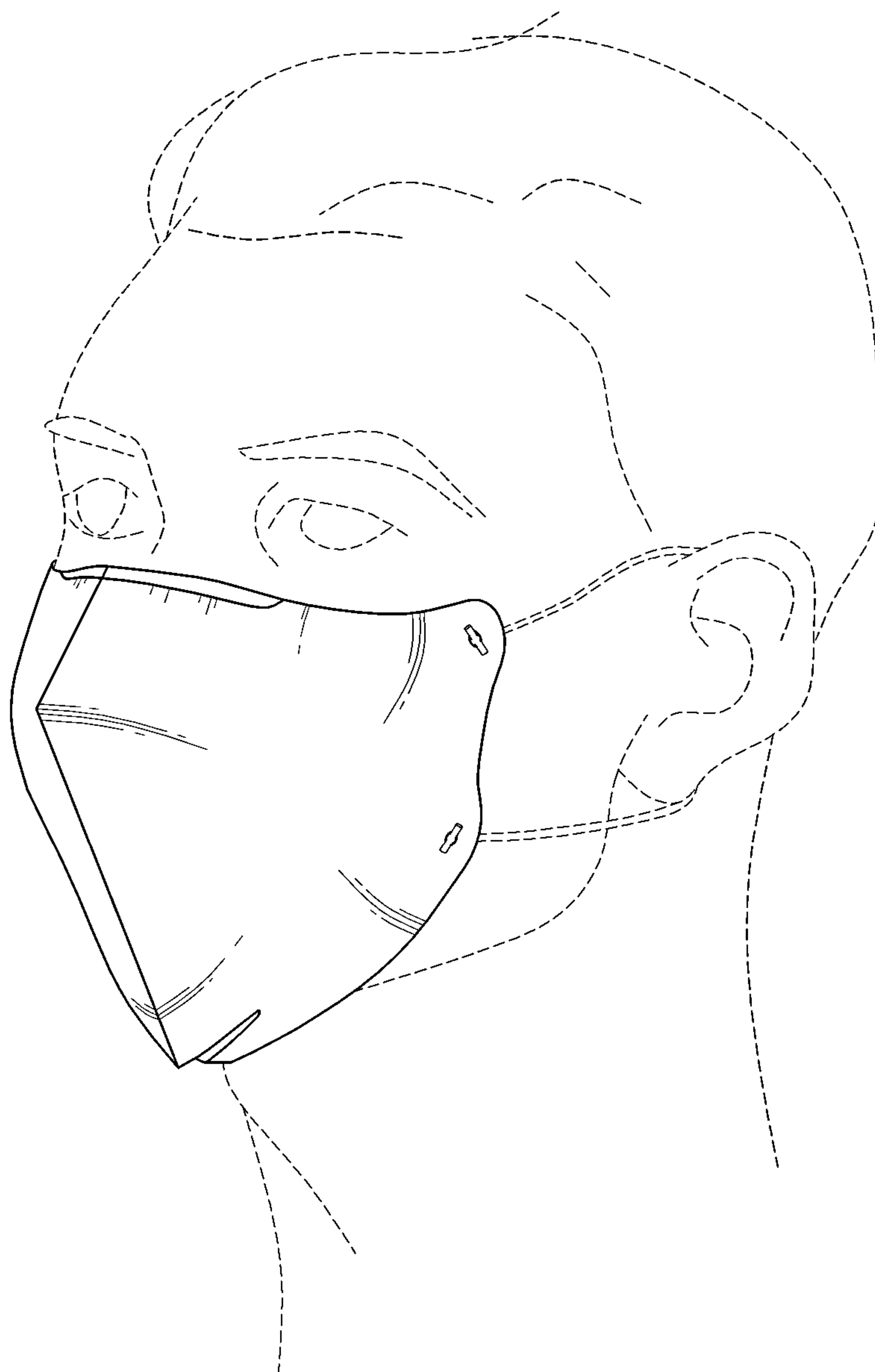


FIG. 10



**FIG. 11**